

1. Record Nr.	UNINA9910710230303321
Autore	Palla Robert L
Titolo	Water usage characteristics of household appliances and the potential for water savings // Robert L. Palla
Pubbl/distr/stampa	Gaithersburg, MD : , : U.S. Dept. of Commerce, National Institute of Standards and Technology, , 1980
Descrizione fisica	1 online resource
Collana	NBSIR ; ; 80-2173
Altri autori (Persone)	Palla Robert L
Lingua di pubblicazione	Inglese
Formato	Materiale a stampa
Livello bibliografico	Monografia
Note generali	1980. Contributed record: Metadata reviewed, not verified. Some fields updated by batch processes. Title from PDF title page.
Nota di bibliografia	Includes bibliographical references.

2. Record Nr.	UNINA9910350337703321
Autore	Shimoda Tatsuya
Titolo	Nanoliquid Processes for Electronic Devices [[electronic resource]] : Developments of Inorganic Functional Liquid Materials and Their Processing / / by Tatsuya Shimoda
Pubbl/distr/stampa	Singapore : , : Springer Singapore : , : Imprint : Springer, , 2019
ISBN	981-13-2953-2
Edizione	[1st ed. 2019.]
Descrizione fisica	1 online resource (XVI, 590 p. 434 illus., 262 illus. in color.)
Disciplina	620.44
Soggetti	Surfaces (Physics) Physical organic chemistry Electronics Industrial engineering Surfaces and Interfaces, Thin Films Physical Chemistry Electronics and Microelectronics, Instrumentation Semiconductors Industrial and Production Engineering
Lingua di pubblicazione	Inglese
Formato	Materiale a stampa
Livello bibliografico	Monografia
Nota di contenuto	Liquid process -- Guide to silicon-based materials -- Liquid silicon -- Thin film formation by coating -- Liquid vapor deposition using liquid silicon (LVD) -- Liquid silicon family materials(1) -- Liquid silicon family materials(2) -- Nano pattern formation using liquid silicon -- Development of solar cells using liquid silicon -- Development of thin film transistors using liquid silicon -- Guide to Oxide-based materials -- Improvement of solid through improved solutions and gels (1) -- Improvement of solid through improved solutions and gels (2) -- Direct imprinting of gel (nano-Rheology Printing) -- Novel materials proper to liquid process -- Thin film oxide-transistor by liquid process (1) -- Thin film oxide-transistor by liquid process (2) -- Thin film oxide-transistor by liquid process (3) -- Device fabrication by n-RP.
Sommario/riassunto	This book summarizes the results of the research on how to make

small electronic devices with high properties by using simple liquid processes such as coating, self-assembling and printing, especially focusing on devices composed of silicon and oxide materials. It describes syntheses and analyses of solution materials, formations of solid thin films from solutions, newly developed patterning methods to make devices, and characterization of the developed devices. In the first part of the book, the research on liquid silicon (Si) materials is described. Because the use of a liquid material is a quite new idea for Si devices, this book is the first one to describe liquid Si materials for electronic devices. Si devices as typified by MOS-FET have been produced by using solid and gas materials. This volume precisely describes a series of processes from material synthesis to device fabrication for those who are interested and are/will be engaged in liquid Si-related work. In the latter part of the book, a general method of how to make good oxide films from solutions and a new imprinting method to make nanosized patterns are introduced. For making oxide films with high quality, the designing of the solution is crucial. If a solution is designed properly, a gel material called "cluster gel" can be formed which is able to be imprinted to form nanosized patterns. The anticipated readers of this book are researchers, engineers, and students who are interested in solution and printing processes for making devices. More generally, this book will also provide guidelines for corporate managers and executives who are responsible for making strategies for future manufacturing processes. .
